



Appl. No. 09/212,726

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No.09/212,726
Filing Date December 15, 1998
Inventor..... Klaus F. Schuegraf
Assignee.....Micron Technology, Inc.
Group Art Unit.....2813
Examiner Blum, David S.
Attorney's Docket No.MI22-1098
Title: Semiconductor Processing Methods of Chemical Vapor Depositing SiO₂ on a
Substrate

RESPONSE TO DECEMBER 1, 2005 FINAL OFFICE ACTION
TO ACCOMPANY RCE FILING

To: Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

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AMENDMENTS

Introductory Comments

In reply to the final office action dated December 1, 2005, applicant amends and
remarks as follows.